

Docket No.: 4006-271



PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

Alex LONG

U.S. Patent Application No. 10/691,520

Filed: October 24, 2003

:  
:  
: Confirmation No. 9118  
:  
: Group Art Unit: 1755  
:  
: Examiner: Michael . Marcheschi

For: ABRASIVE ARTICLE AND MANUFACTURING METHOD THEREOF

Dear Sir:

Transmitted herewith is an Amendment in the above identified application.

- ☒ No additional fee is required.  
☐ Small entity status of this application has been established.  
☐ Also attached:

The fee has been calculated as shown below:

	NO. OF CLAIMS	HIGHEST PREVIOUSLY PAID FOR	EXTRA CLAIMS	RATE	FEE
Total Claims	55	71	0	x \$ 50 =	\$ 0.00
Independent Claims	4	5	0	x \$200 =	\$ 0.00
If multiple claims newly presented, add \$360.00					
Fee for extension of time					
TOTAL FEE DUE					\$ 0.00

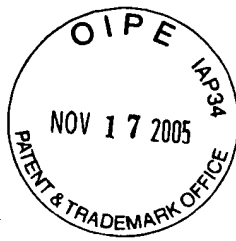
- ☐ A credit card authorization form in the amount of \_\_\_\_\_ is attached
- ☒ The Commissioner is hereby authorized to charge payment of any *deficiency* in fees associated with this communication or credit any overpayment, to Deposit Account No. 07-1337, including any filing fees under 37 CFR 1.16 for presentation of extra claims and any patent application processing fees under 37 CFR 1.17.

Respectfully submitted,

LOWE HAUPTMAN & BERNER, LLP

Benjamin J. Hauptman  
Registration No.: 29,310

USPTO Customer No. 22429  
1700 Diagonal Road, Suite 300  
Alexandria, Virginia 22314  
(703) 684-1111 BJH/jk  
(703) 518-5499 Facsimile  
Date: November 17, 2005



Docket No.: 4006-271

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of	:	
Alex LONG	:	Confirmation No. 9118
U.S. Patent Application No. 10/691,520	:	Group Art Unit: 1755
Filed: October 24, 2003	:	Examiner: Michael A Marcheschi

For: ABRASIVE ARTICLE AND MANUFACTURING METHOD THEREOF

AMENDMENT

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

This paper is in response to the Official Action mailed August 18, 2005. Applicant respectfully submits the following amendments and comments in connection with the above-named application.